

Twenty-third International Summer School  
18 - 22 September 2023  
Sozopol, Bulgaria



**V**acuum  
**E**lectron  
**I**on  
**T**echnologies

**PROGRAM  
ABSTRACTS**



**TWENTY-THIRD INTERNATIONAL SUMMER SCHOOL ON  
VACUUM, ELECTRON AND ION TECHNOLOGIES**

# VEIT 2023

**18 - 22 September 2023  
SOZOPOL, BULGARIA**

*Jointly organized by the Institute of Electronics of the Bulgarian  
Academy of Sciences and the Dutch Institute for Fundamental  
Energy Research, The Netherlands*



*Dedicated to the 60<sup>th</sup> Anniversary  
of the Bulgarian organizer of the event*

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VACUUM, ELECTRON AND ION TECHNOLOGIES**

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**Editors: M. Dimitrova, Ch. Ghelev, B. Georgieva and E. Vasileva**

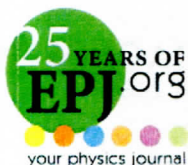


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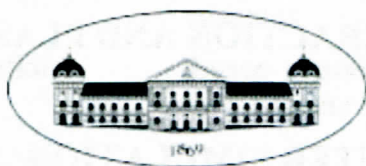
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BULGARIAN ACADEMY OF SCIENCES, SOFIA, BULGARIA

**DUTCH INSTITUTE FOR FUNDAMENTAL ENERGY RESEARCH**  
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Young Researcher Attendance Grant



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## MAIN SCIENTIFIC TOPICS:

- THIN FILMS DEPOSITION
- SURFACES AND THIN FILMS PROCESSING AND ANALYSIS
- COATINGS FOR ADVANCED APPLICATIONS
- NEW MATERIALS
- PLASMA-SURFACE INTERACTION AND PLASMA DIAGNOSTICS
- GREEN TECHNOLOGIES
- MODELING AND COMPUTER SIMULATION

## PLENARY AND POSTER SESSIONS:

### A: THIN-FILMS DEPOSITION

COATINGS FOR ADVANCED APPLICATIONS

B: NEW MATERIALS. PLASMA-SURFACE INTERACTION AND  
PLASMA DIAGNOSTICS. GREEN TECHNOLOGIES. MODELING  
AND COMPUTER SIMULATION

C: SURFACES AND THIN FILMS PROCESSING AND ANALYSIS

### ABBREVIATIONS:

TL – TOPIC LECTURE  
PR – PROGRESS REPORT  
OP – ORAL PRESENTATION  
PA – POSTER SESSION A  
PB – POSTER SESSION B  
PC – POSTER SESSION C



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## POST DEADLINE CONTRIBUTION

PB-27**LOW-TEMPERATURE MICROWAVE PLASMA AT ATMOSPHERIC PRESSURE  
WITH AEROSOLS: TREATMENT OF LIQUID SAMPLES**

N. Babucić, N. Škoro and N. Puač

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The investigation of low-temperature plasma (LTP) has revealed a wide range of applications, particularly in water decontamination, wound treatment using plasma-activated liquid (PAL), and agricultural practices. PAL contains reactive species and, consequently, has antimicrobial and antibacterial effect influencing the cells at different levels. However, one of the main challenges in plasma-water interaction is enhancing the flux of reactive species from the plasma. To address this challenge, the introduction of micrometer-scale aerosol droplets immersed in plasma has proven promising. This configuration offers a high surface-to-volume ratio, significantly increasing the contact area for water and potentially leading to higher rates of chemical interaction between the plasma in the gas phase and the liquid.<sup>1</sup>

To optimize the properties of PAL, it becomes necessary to employ various plasma sources, one of them being microwave plasma source. In the current phase of the experiment, the plasma operates with an argon flow ranging from 1 – 7 slm, without the addition of aerosols. The inductively-coupled surface-wave launcher facilitates the transfer of energy from the microwave generator to the plasma, allowing for uniform plasma formation within the quartz tube. This configuration offers advantages, such as high efficiency, plasma stability, and reduced risk of electrode contamination, making it a possible preferred choice for generating LTP in research and industrial applications.

Our analysis involved studying recordings of emissions originating from various regions of the plasma, using images to capture the spatial structure and optical emission spectra. To determine the presence of reactive nitrogen and oxygen species in plasma-activated liquid (PAL), colorimetric techniques were employed.

By assembling an experiment utilizing a microwave (MW) plasma source for aerosol treatment, we aim to characterize the plasma, study the interaction between plasma and droplets, and analyze the treated water to gain a better understanding of the high chemical reactivity gas-liquid reactions.

**Acknowledgment:**

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**References:**

1. Stancampiano A., Galligani T., Gherardi M., et al., Applied Sciences, 9(18) (2019), 3861, 10.3390/app9183861c